

Europäisches Patentamt

European Patent Office

Office européen des brevets



(11) EP 0 778 611 A3

(12)

EUROPEAN PATENT APPLICATION

(88) Date of publication A3: 12.05.1999 Bulletin 1999/19

(51) Int Cl.6: H01L 21/00

(43) Date of publication A2: 11.06.1997 Bulletin 1997/24

(21) Application number: 96306581.8

(22) Date of filing: 11.09.1996

(84) Designated Contracting States: AT BE CH DE ES FR GB GR IE IT LI NL SE

(30) Priority: 08.12.1995 US 569760

(71) Applicant: APPLIED MATERIALS, INC. Santa Clara, California 95054-3299 (US)

(72) Inventors:

Marohl, Dan A.
 San Jose, California 95123 (US)

 Ngan, Kenny King-Tai Fremont, California 94539 (US)

 (74) Representative: Bayliss, Geoffrey Cyril et al BOULT WADE TENNANT,
 27 Furnival Street
 London EC4A 1PQ (GB)

(54) End effector for semiconductor wafer transfer device and method of moving a wafer with an end effector

(57) An end effector (20) for a transfer robot (10) used in connection with the manufacture of semiconductor wafers is provided. The end effector is designed to handle very thin (.005" - .010") semiconductor wafers (W) which tend to bow during processing. The robot blade or end effector includes a deep pocket (26) for receiving a bowed wafer. The depth of the pocket may be varied depending upon the degree of bowing in the

wafers to be handled. Unlike ordinary wafer transfer devices, the present invention requires the wafer to be transferred with the surface bearing the devices facing down. The deep pocket allows the end effector to contact only the edges of the wafer, thus minimizing any defects across the wafer due to handling. The pocket opening is provided with arcuately shaped sloped wafer contact surfaces (24, 25a, 25b) to prevent wafer sliding during robot movement.

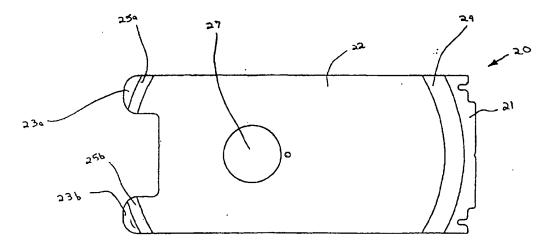


FIG 3



F.za. 4



EUROPEAN SEARCH REPORT

Application Number

EP 96 30 6581

	014-41	ERED TO BE RELEVANT dication, where appropriate.	Delevent	01 +001010 : 7:0	4. OF TUE
Category	of relevant passa		Relevant to claim	CLASSIFICATION APPLICATION	
X A	EP 0 669 642 A (APPI 30 August 1995 * column 6, line 25 claims 19,20; figure	- column 7, line 24;	1-5,12, 14,25-28 11,17	H01L21/00	
A	US 5 314 294 A (TAN: 24 May 1994 * figures *	IGUCHI TAKAO ET AL)	1		
				TECHNICAL FIE	LDS (Int.Cl.6)
				H01L	
	The present search report has b				
	THE HAGUE	Date of completion of the search 18 March 1999	Rio	Examiner utort, A	
X : parti Y : parti docu A : tech O : non-	ATEGORY OF CITED DOCUMENTS cularly relevant if taken alone cularly relevant if combined with anoth ment of the same category nological background written disclosure mediate document	T : theory or princ E : earlier patent o after the filling o or D : document cite L : document cite	iple underlying the in document, but publis date of in the application of for other reasons	wentian hed on, or	

PO FORM 1500 IS 89

EP 0 778 611 A3

ANNEX TO THE EUROPEAN SEARCH REPORT ON EUROPEAN PATENT APPLICATION NO.

EP 96 30 6581

This annex lists the patent family members relating to the patent documents cited in the above-mentioned European search report. The members are as contained in the European Patent Office EDP file on The European Patent Office is in no way liable for these particulars which are merely given for the purpose of Information.

18-03-1999

01-07-199
10-11-199
12-02-199 04-02-199

For more details about this annex : see Official Journal of the European Patent Office, No. 12/82